# **Niklas Roschewsky**

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## SUMMARY

Senior Data Scientist with 6+ years of experience specializing in applying machine learning to complex simulation and process control challenges in the semiconductor industry. Proven track record of leading teams and delivering high-value analytics products, from conception to integration, to create virtual twins of physical systems. Expertise in technical leadership, Bayesian optimization, and surrogate modeling.

### **EXPERIENCE**

#### Senior Data Scientist & Technical Owner

Lam Research

Jul 2020 - Present Portland, OR

- Architected and led the development of a production AI system for model calibration and yield improvement, reducing solution deployment time from months to weeks and decreasing computational costs by 50%.
- Pioneered a novel algorithmic framework for semiconductor process optimization, reducing recipe development R&D cycles by an
  estimated 40%. This foundational research was published in Nature (2023), establishing Lam as an industry leader in Al-driven R&D.
- Defined and executed the technical roadmap for the data science team, aligning algorithmic development with C-level business objectives for yield improvement and cost reduction.
- Directed the team's agile scrum process, improving on-time project delivery rates by 25% quarter-over-quarter and mentoring 3 data scientists in ML best practices.

**Rotation Engineer**Jul 2019 – Jul 2020
Lam Research
Fremont, CA

- Selected for Lam's competitive engineering rotation program, gaining cross-functional expertise in hardware, customer engineering, and data analytics that directly informs my current data science work.
- Engineered and deployed a real-time data pipeline and monitoring dashboard for hardware telemetry, reducing tool diagnostic time by 50% and improving overall equipment effectiveness.
- Led root-cause analysis for critical customer escalations, using statistical analysis of hardware defect data to recommend
  engineering solutions that prevented recurrence.

#### **Device Engineer Intern**

Samsung Semiconductor

May 2017 – Aug 2017 Santa Clara, CA

- Designed and fabricated a novel test apparatus to characterize device performance under mechanical stress, providing key data for next-generation memory reliability models.
- Authored and published the experimental findings in the peer-reviewed journal Applied Physics Letters, validating the measurement methodology.

#### TECHNICAL SKILLS

Machine Learning & Optimization: Bayesian Optimization, Surrogate Modeling (Gaussian Processes), Deep Learning, Uncertainty Quantification, PyTorch, BoTorch, GPyTorch, Scikit-learn

Data Engineering & MLOps: Databricks, MLflow, Docker, CI/CD (Azure DevOps), Data Pipelines

Core Scientific Stack: Python, Pandas, NumPy, SciPy, Linux/Unix, Slurm

## **EDUCATION**

**University of California, Berkeley** 

Ph.D in Physics

Berkeley, CA Aug 2014 – May 2019

**Technical University of Munich** 

MS in Physics

Munich, Germany Oct 2012 – Jul 2014

**University of Göttingen** 

B.Sc. in Physics

Göttingen, Germany Oct 2009 – Jul 2012

## **SELECTED PUBLICATIONS & PATENTS**

A selection demonstrating expertise in quantitative modeling, experimental design, and solving complex problems in physical systems.

- K. J. Kanarik, ... **N. Roschewsky**, et al. Human-machine collaboration for improving semiconductor process development. *Nature* **616**, 707–711 (2023).
- N. M. Wilson, **N. Roschewsky**, S. Ramachandran. Method for Conditioning a Plasma Processing Chamber. U.S. Pat. App. Pub. No. 2023/0122167.
- N. Roschewsky, T. Matsumura, S. Cheema, et al. Spin-orbit torques in ferrimagnetic GdFeCo alloys. *Appl. Phys. Lett.* **109**, 112403 (2016).
- N. Roschewsky, E. S. Walker, P. Gowtham, et al. Spin-orbit torque and Nernst effect in Bi-Sb/Co heterostructures. *Phys. Rev. B* 99, 195103 (2019).

(For a complete list of 13 peer-reviewed publications, see my Google Scholar profile.)

## **AWARDS & HONORS**

**Studienstiftung des deutschen Volkes Fellowship:** Germany's most prestigious merit-based scholarship, awarded to fewer than 0.5% of German students.

Berkeley Gateway Fellowship: Merit-based fellowship for doctoral studies at UC Berkeley.